

# Thermal Noise in Thin Silicon Structures

**Matthew Winchester** 

Mentors: Nicolas Smith, Zach Korth, and Rana Adhikari August 20, 2015



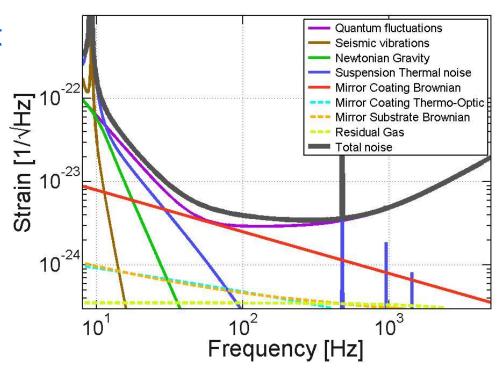
#### Overview

- Motivation
- Thermal noise
- Damped oscillator review
- Fluctuation-Dissipation Theorem
- Experimental design
- Measurements
- Conclusions



## Motivation – Increase Future Detector Sensitivity

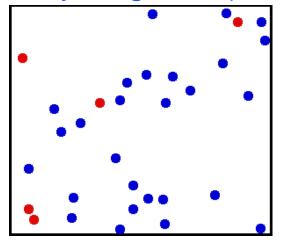
- Reduce thermal noise in suspensions and test masses
- Current detectors use fused silica
- Crystalline silicon is being considered for future detectors
  - » Favorable material properties (more on this later)





### Thermal Noise in LIGO

- Temperature is a measure of average kinetic energy
- Random thermal fluctuations couple to displacement noise in detector
- How do we reduce the shaking in our test masses?
  (without cooling everything to 0K)

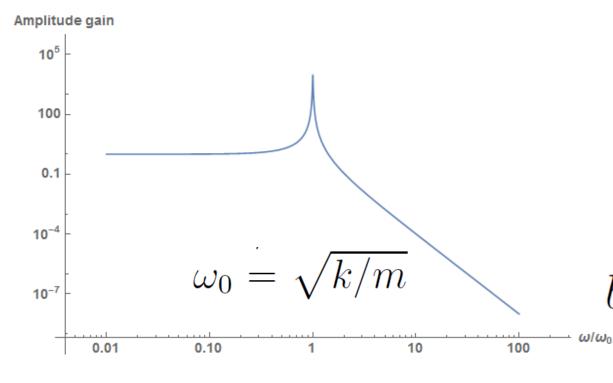


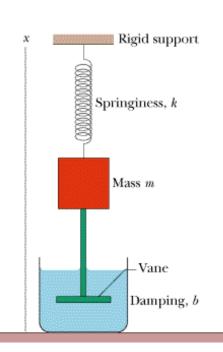


## Underdamped Oscillator Review

Equation of motion:  $m\ddot{x} + b\dot{x} + kx = f_{ext}$ 

Frequency response: 
$$H(s) = \frac{X(s)}{F_{ext}(s)} = \frac{1}{ms^2 + bs + k}$$



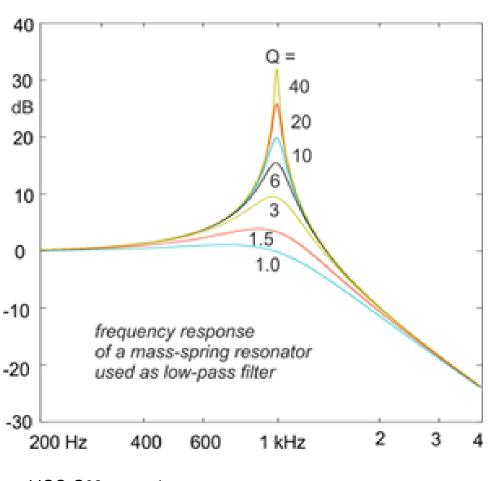


#### Underdamped:

$$b^2/4km \ll 1$$



## Quality Factor Q



$$Q = \frac{\omega_0}{\Delta \omega}$$

$$Q = \frac{\omega_0 m}{b}$$

LIGO-G09xxxxx-v1



## Internal Damping

$$m\ddot{x} + k(1+i\phi)x = f_{ext} \iff m\ddot{x} + b\dot{x} + kx = f_{ext}$$

Restorative force leads displacement by loss angle  $\phi$ 

$$Q = \frac{1}{\phi}$$

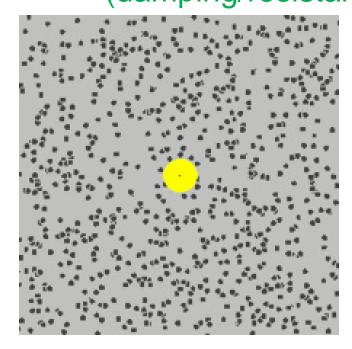


# How are losses in oscillators related to thermal noise?



## Fluctuation-Dissipation Theorem

 FDT relates thermal fluctuations (noise) to dissipation (damping/resistance/loss)



$$\langle x^2 \rangle = 2 Dt$$

Brownian motion

$$\langle V^2 \rangle = 4k_B T R \delta v$$

Johnson noise



# Thermal Noise in Damped Oscillators

Thermal noise power spectrum:

$$x^{2}(\omega) = \frac{4k_{B}Tk\phi}{\omega[(k - m\omega^{2})^{2} + k^{2}\phi^{2}]}$$

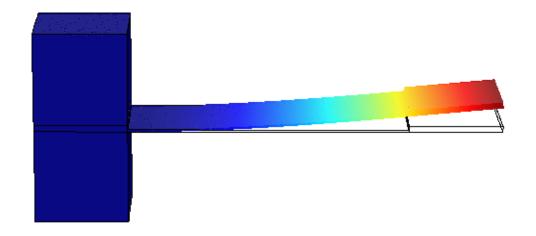
Away from resonance:

$$\langle x_{th}^2 \rangle \propto \frac{T}{Q}$$

We want to design high Q, low loss silicon resonators



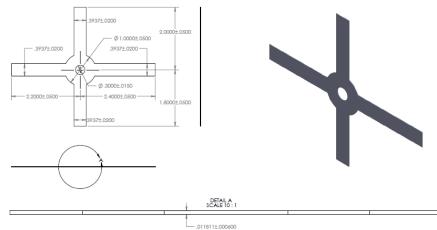
# Our Resonators – Silicon Cantilevers

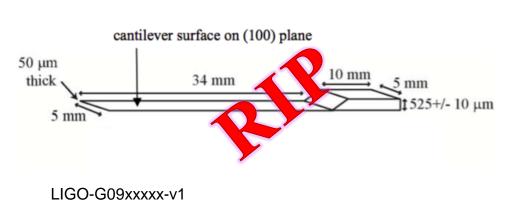




## Silicon Cantilever Design



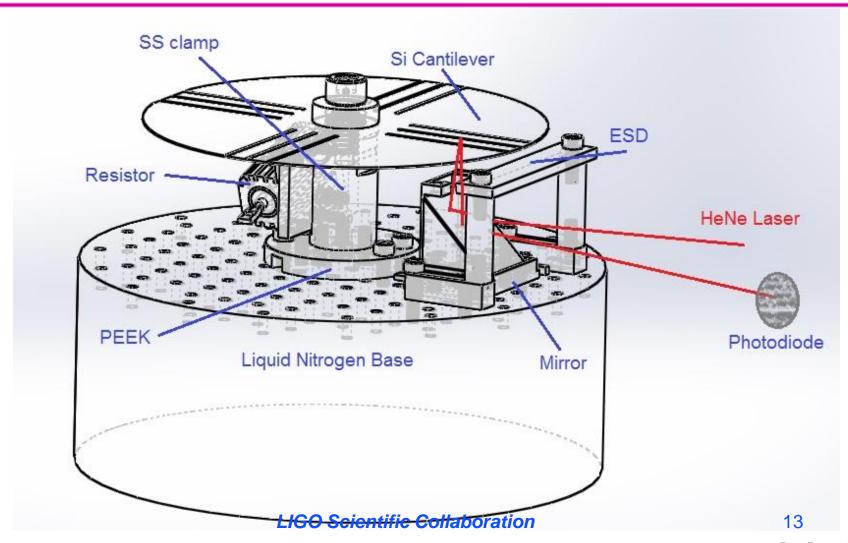






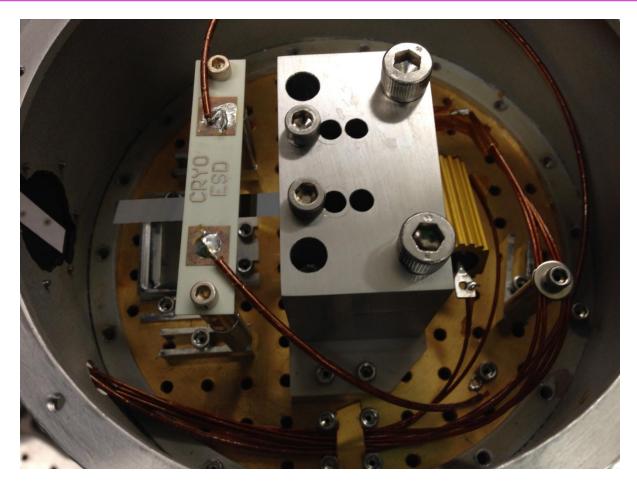


## **Experimental Design**



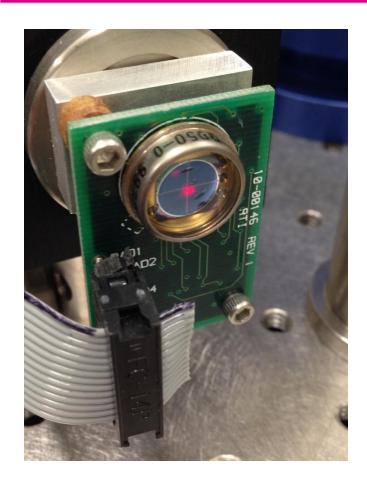


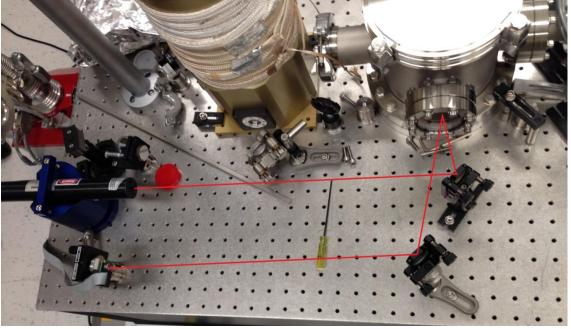
## **Experimental Design**





## Experimental Design - Optics

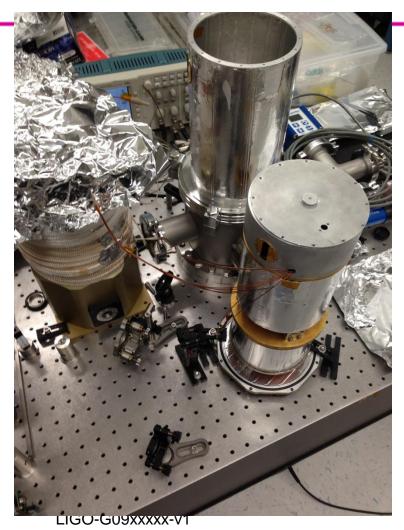


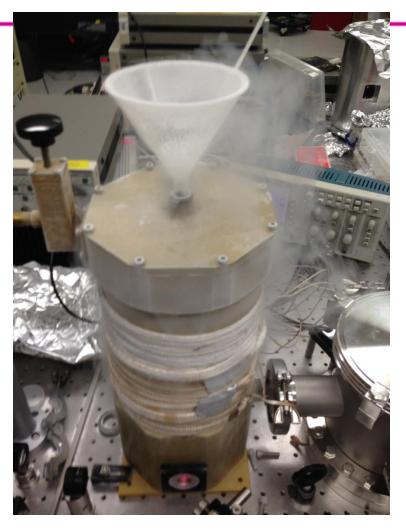


LIGO-G09xxxxx-v1



## Experimental Design – Insulation

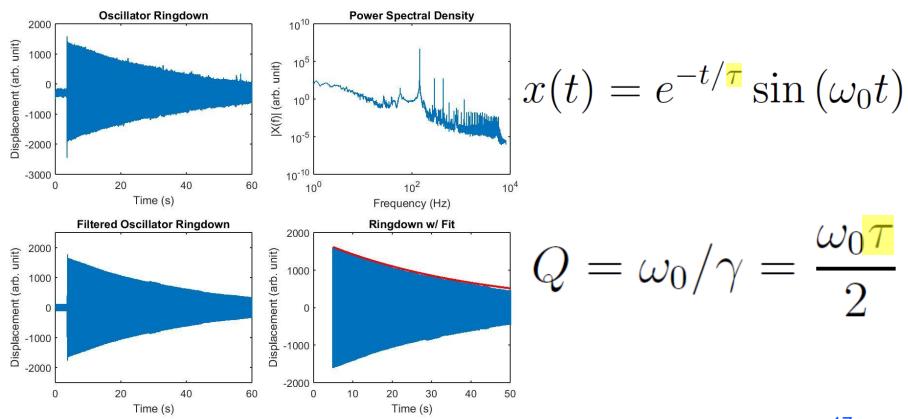






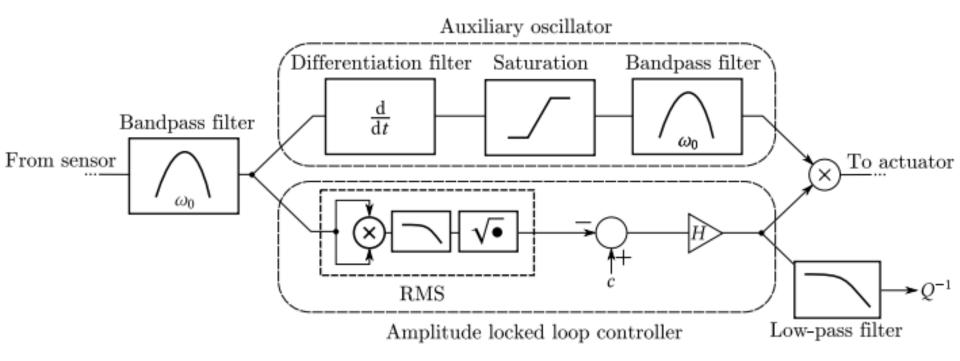
## Ringdown Measurement

#### Excite cantilever with impulse and watch free decay





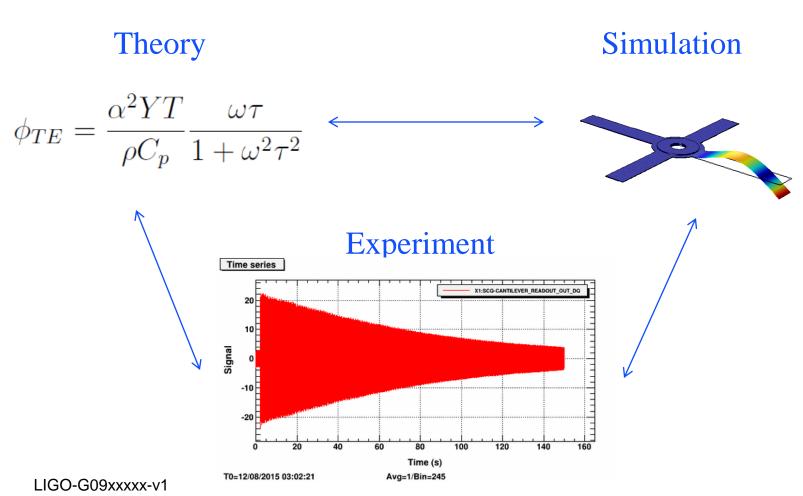
### Continuous Measurement



- Cantilever is continuously driven at constant amplitude
- Less sensitive to background excitations
- Measures Q over temperature sweeps, etc.



## Making Conclusions about Losses





### Sources of Loss

- Thermoelastic loss
- Clamp loss
- Surface loss
- Phonon-phonon loss
- Gas damping
- Bulk loss
- Excess losses



### Thermoelastic Loss

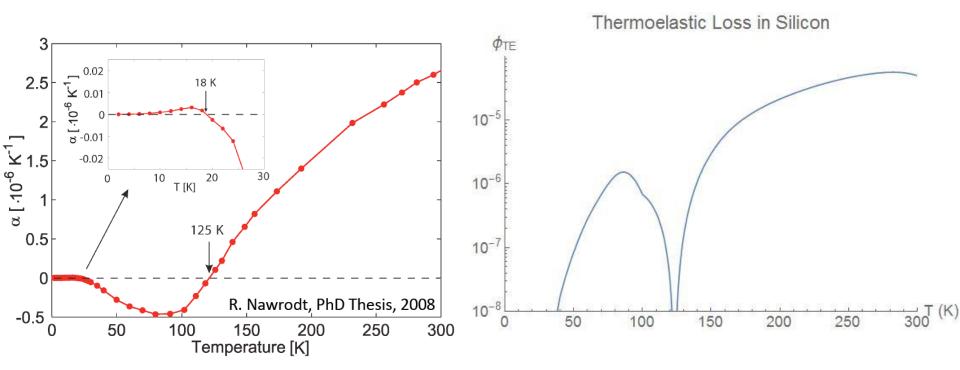
- Coefficient of thermal expansion couples strain to temp.
- Heat fluxes driven by temp. gradient dissipate energy

• Heat fluxes driven by temp. gradient dissipate energy 
$$\phi_{TE} = \frac{\alpha^2 YT}{\rho C_p} \frac{\omega \tau}{1+\omega^2 \tau^2}$$
 
$$\tau = \frac{\rho C_p t^2}{\pi \kappa}$$



#### Thermoelastic Loss cont.

• Silicon has a vanishing  $\alpha$  at T=125K





#### TE Loss Conclusions

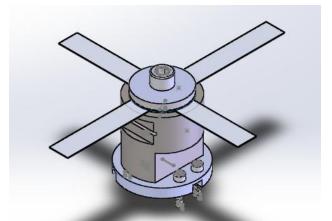
- Don't see dramatic increase in Q at 125K
- Q is ~2 orders of magnitude lower than TE loss limited prediction
- Not TE loss limited

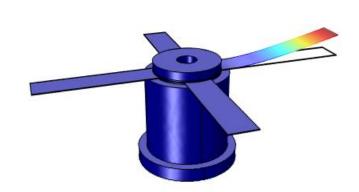


## Clamp Loss

 Energy is transferred from cantilever and stored in clamp, base, etc. as strain energy

$$\phi_{measured} \approx \phi_{Si} + \frac{E_{clamp}}{E_{total}} \phi_{clamp} + \frac{E_{PEEK}}{E_{total}} \phi_{PEEK} + \dots$$







## Clamp Loss Conclusions

- Simulations predict that very little strain energy is stored in clamp, washers, base, etc.
- New clamp designs don't significantly improve Q
- Reclamping doesn't change Q
- Not clamp loss limited

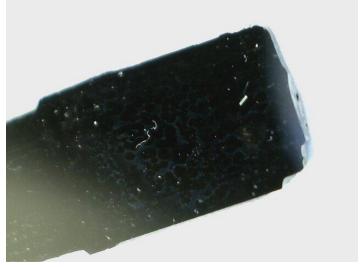
Eigenfrequency (Hz)	$E_{pinwheel}$ (arb. unit)	$E_{clamp}$ (arb. unit)	Ratio
161	3016	3.4	1.1e-3
1009	120264	139	1.2e-3
1449	212434	160	0.8e-3



### **Surface Loss**

 Surface roughness, lattice imperfections, adsorbed surface materials, etc. contribute to a lossy surface







### Surface Loss Conclusions

- Cantilever surfaces clearly show surface defects
- Cleaning doesn't improve Q (?)
- Lossy surface layers in simulation accurately predict experimental results
- Much more work to be done investigating different etching techniques
- Candidate for dominant loss source



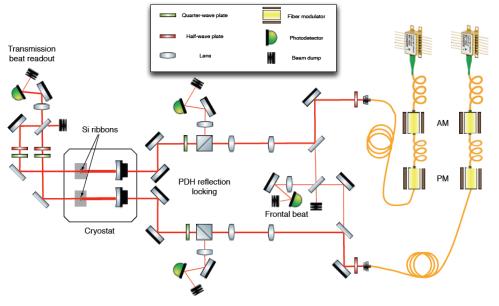
## Summary

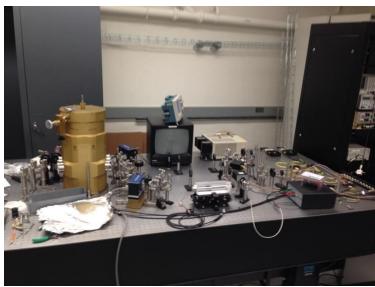
- No quality factor peak at 125K not TE limited
- Simulation shows low strain energy ratios not clamp loss limited
- Most likely surface loss limited lossy surfaces in simulation match experiment
- Developed technique for continuous measurements of several resonant modes simultaneously – speed up future Q measurements



#### **Future Work**

- Experiment with different etching techniques
- Investigate loss in thin films and optical coatings
- Direct thermal noise measurements





LIGO-G09xxxxx-v1



## Acknowledgements

- My mentors: Zach, Nic, and Rana
- Fellow SURF students
- LIGO Scientific Collaboration faculty
- NSF and Caltech

Thanks for a great summer!

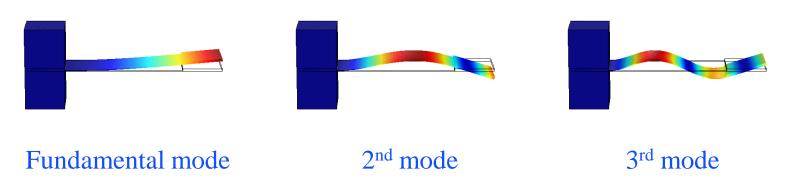


## Questions?



#### **COMSOL Mode Simulations**

#### **Normal Modes**



#### **Torsional Modes**



LIGO-G09xxxxx-v1